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Docket No.: 005916 USA/FPS/MMCS/MC

PATENT/OFFICIAL

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Young Joseph PAIK

Serial No. 09/998,384

: Group Art Unit: 2812

Filed: November 30, 2001

: Examiner:

For:

FEEDFORWARD AND FEEDBACK CONTROL FOR CONDITIONING OF

CHEMICAL MECHANICAL POLISHING PAD

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner for Patents Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

This submission does not constitute a representation that a search has been made or that no better art exists and does not constitute an admission or representation that any of the listed documents is material or constitutes prior art. If it should be determined that any of the listed documents does not constitute prior art under the United States law, Applicants reserve the right

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to present to the Office the relevant facts and law regarding the appropriate status of such document.

No certification or fee is believed to be required. However, the Commissioner is hereby authorized to charge any additional fees should any be required for this submission, or credit any overpayment to deposit account no. 08-0219.

Respectfully submitted,

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ATTY. DOCKET NO. SERIAL NO. 09/998,384 005916 INFORMATION DISCLOSURE USA/FPS/MMCS/MC CITATION IN AN APPLICATION (PTO-1449) APPLICANT Young Joseph PAIK FILING DATE GROUP November 30, 2001 2812 **U.S. PATENT DOCUMENTS** FILING DATE **EXAMINER'S** INITIALS PATENT NO. DATE CLASS **SUBCLASS** NAME 5,901,313 05/04/99 Wolf et al. 09/02/97 6,002,989 12/14/99 Shiba et al. 04/01/97 6,094,688 07/25/00 03/12/98 Mellen-Garnett et al. 6,340,602 01/22/02 Johnson et al. 02/12/01 6,345,288 02/05/02 Reed et al. 05/15/00 6,368,879 04/09/02 Toprac 09/22/99 US-08/08/02 Riley et al. 12/06/00 2002/0107604 6,470,230 10/22/02 Toprac et al. 01/04/00 03/19/01 6,482,660 11/19/02 Conchieri et al. 01/19/00 6,567,717 05/20/03 Krivokapic et al. FOREIGN PATENT DOCUMENTS **EXAMINER'S** Translation PATENT NO. CLASS SUBCLASS INITIALS DATE COUNTRY Yes No WIPO X WO 99/59200 11/18/99 WO 01/52319 07/19/01 WIPO X OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.) Williams, Randy, Dadi Gudmundsson, Kevin Monahan, Raman Nurani, Meryl Stoller and J. George Shanthikumar. October 1999. "Optimized Sample Planning for Wafer Defect Inspection," Semiconductor Manufacturing Conference Proceedings, 1999 IEEE International Symposium on Santa Clara, CA. Piscataway, NJ. pp. 43 - 46. 23 July 2003. Invitation to Pay Additional Fees and Communication Relating to the Results of the Partial International Search for PCT/US02/19116. 01 August 2003. Written Opinion for PCT/US01/27406. 20 August 2003. Written Opinion for PCT/US01/22833. **EXAMINER DATE CONSIDERED**

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.